

REMARKS

Claims 11-18 and 23-25 are pending in this application. Claims 19 and 20 stand withdrawn.

By this Amendment, independent claims 11 and 23 are amended for better clarity.

See the specification at, for example, Fig. 1.

Reconsideration of the application is respectfully requested.

Applicant thanks Examiner Tran for the courtesy extended to Applicant's representative, Mr. Luo, during the February 3, 2006 personal interview. The substance of the personal interview is incorporated in the following remarks.

The Office Action rejects claims 11-17 and 23 under 35 U.S.C. §103(a) over U.S. Patent 6,891,248 to Akram et al. ("Akram") in view of U.S. Patent 6,323,542 to Hashimoto ("Hashimoto") and U.S. Patent 6,534,386 to Irie ("Irie"); and rejects claim 18 under 35 U.S.C. §103(a) over Akram in view of Hashimoto and Irie, and further in view of U.S. Patent 6,242,156 to Teng ("Teng"). These rejections are respectfully traversed.

As discussed during the personal interview, Akram, Hashimoto, Irie and Teng, either individually or in combination, do not disclose or suggest forming a second resin layer over a first resin layer and in contact with a semiconductor wafer, the first and second resin layers having no wiring therebetween, as recited in claim 11, and similarly recited in claim 23. Therefore, Akram, Hashimoto, Irie and Teng either individually or in combination, do not disclose or suggest the subject matter recited in claims 11 and 23, and claims 12-18, 24 and 25 depending therefrom. Accordingly, as agreed to during the personal interview, withdrawal of the rejection of claims 11-18 and 23-25 under 35 U.S.C. §103(a) is respectfully requested.

Claims 19 and 20 depend from claim 11. Thus, rejoinder and allowance of claims 19 and 20 are respectfully requested.

In view of the foregoing, it is respectfully submitted that this application is in condition for allowance. Favorable reconsideration and prompt allowance of claims 11-20 and 23-25 are earnestly solicited.

Should the Examiner believe that anything further would be desirable in order to place this application in even better condition for allowance, the Examiner is invited to contact the undersigned at the telephone number set forth below.

Respectfully submitted,



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Attachment:

Request for Continued Examination

Date: March 29, 2006

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